EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	9825	430/5.ccls.	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:28
L2	24052	(phas\$3 or shift\$3) near3 (mask or photomask or reticle) or \$3PSM	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:29
L3	3555	line end short\$5 or (short \$5 or shrink\$3) near3 (end or tip) near3 (line or rectangle)	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:29
L4	538844	resist or photoresist	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:30
L5	1812544	memory or DRAM or SRAM or \$3ROM	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:31
L6	160	2 same isolated same dense same (pattern or portion or area or region)	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:32
L7	3	1 and 6 and 3 same 4 and 5	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:33
L8	2	1 and 6 and 3 same 4 not 7	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:33
L9	1	1 and 6 and 3 not 7 not 8	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:34
L10	5	6 and 3 not 7 not 8 not 9	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:34
L11	102	1 and 6 not 7 not 8 not 9 not 10	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:35

L12	47	6 not 7 not 8 not 9 not 10 not 11	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:36
L13	18	1 and 2 same isolated same dense not 7 not 8 not 9 not 10 not 11 not 12	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:37
L14	29	1 and (2 same 3) not 7 not 8 not 9 not 10 not 11 not 12 not 13	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:38
L15	15	2 same (line (end or tip) short\$5 or "LES" or "EOL" or short\$5 (end or tip)) and 5 not 7 not 8 not 9 not 10 not 11 not 12 not 13 not 14	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:43
L16	13	1 and (2 same (halftone or semitransparen\$2 or semi transparen\$2 or partial\$2 transparen\$2 or attenuat\$3) or HPSM or att PSM or attPSM) and 3 same 4 not 7 not 8 not 9 not 10 not 11 not 12 not 13 not 14 not 15	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:47
L17	7	1 and 2 same (("90. DEG." and "180.DEG.") or ("90" degree and "180" degree)) same (recess\$3 or etch\$3) same (substrate or base or support) not 7 not 8 not 9 not 10 not 11 not 12 not 13 not 14 not 15 not 16	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:49
L18	1	2 same (("90.DEG." and "180.DEG.") or ("90" degree and "180" degree)) same (recess\$3 or etch\$3) same (substrate or base or support) not 7 not 8 not 9 not 10 not 11 not 12 not 13 not 14 not 15 not 16 not 17	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:50

L19	35	1 and 2 same (("90. DEG." and "180.DEG.") or ("90" degree and "180" degree)) not 7 not 8 not 9 not 10 not 11 not 12 not 13 not 14 not 15 not 16 not 17 not 18	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:51
L20	15	or "90" degree) not 7 not	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:52
L21	44	1 and 2 same (pair or couple or double or two or second) near2 (opposit \$2 or separat\$3 or across or spaced apart) near2 (group or area or portion or region or pattern or line or isolated or dense or fac\$3) not 7 not 8 not 9 not 10 not 11 not 12 not 13 not 14 not 15 not 16 not 17 not 18 not 19 not 20	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:53
L22	1	Cheng-Yung-Feng.in. not 7 not 8 not 9 not 10 not 11 not 12 not 13 not 14 not 15 not 16 not 17 not 18 not 19 not 20 not 21	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:56
L23	46	as. and 1 and 2 not 7 not 8 not 9 not 10 not 11	US- PGPUB; USPAT; EPO; JPO	ADJ	ON	2008/10/01 18:57
L24	0	(2 and (("90.DEG." and "180.DEG.") or ("90" degree and "180" degree) or "90.DEG." or "90" degree) and isolated and dense and (neighbor\$3 or adjacent \$2 or "next to" or near \$3) and (differ\$3 or another or second or third or fourth) near2 (direct\$3 or exten\$4 or orient\$6 or arrang\$4 or position\$3 or locat\$3)). clm.	US- PGPUB; USPAT	ADJ	ON	2008/10/01 19:12

10/1/08 7:15:01 PM

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